

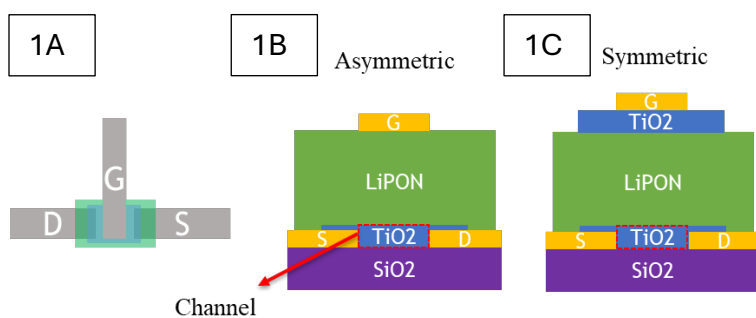


Figure 1: A vertical device top view, B vertical asymmetric cross section, C vertical symmetric cross section

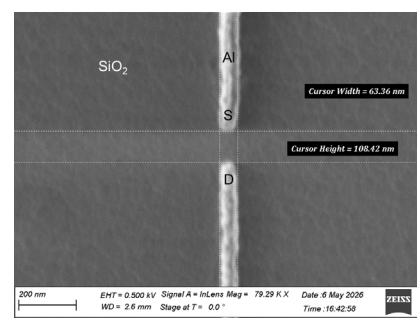


Figure 2: Source and drain fine line lithography for vertical device

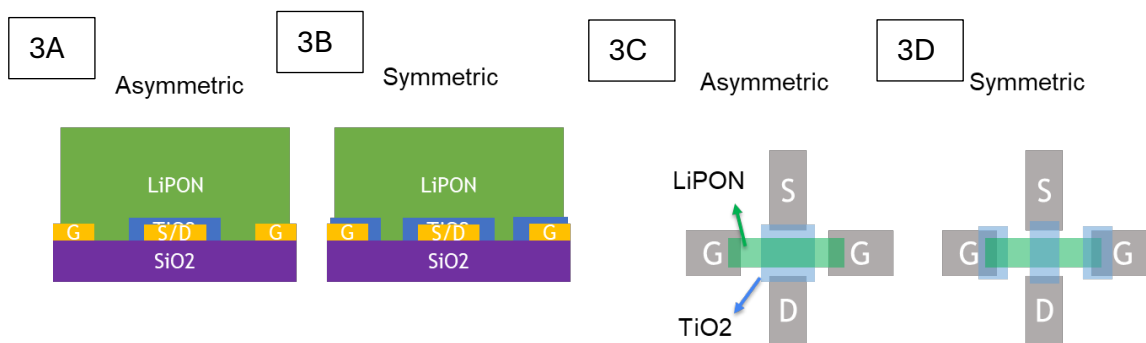


Figure 3: A lateral asymmetric device cross section, B lateral symmetric device cross section, C lateral asymmetric device top view, D lateral symmetric device top view